

**Box No. VIII (ii) DECLARATION: ENTITLEMENT TO APPLY FOR AND BE GRANTED A PATENT**

*The declaration must conform to the standardized wording provided for in Section 212; see Notes to Boxes Nos. VII, VIII (i) to (v) (in general) and the specific Notes to Box No. VIII (ii). If this Box is not used, this sheet should not be included in the request.*

Declaration as to the applicant's entitlement, as at the international filing date, to apply for and be granted a patent (Rules 4.17(ii) and 51 bis.1(a)(ii)), in a case where the declaration under Rule 4.17(iv) is not appropriate:

in relation to this international application,

TENG Jing Hua, CHUA Soo Jin and DONG Jian Rong are entitled to apply for and be granted a patent by virtue of the following:

TENG Jing Hua of Blk 704, West Coast Road, #13-409, Singapore 120704;  
CHUA Soo Jin of 37 Cheng Soon Crescent, Singapore 559909; and  
DONG Jian Rong of Blk 305, Clementi Avenue 4, #06-429, Singapore 120305  
are the inventors of the subject matter for which protection is sought by way of this international application.

This declaration is made for the purposes of the following designations for national and/or regional patents: US.

This declaration is continued on the following sheet, "Continuation of Box No. VIII (ii)".

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Sheet No. 5

**Box No. VIII (ii) DECLARATION: ENTITLEMENT TO APPLY FOR AND BE GRANTED A PATENT**

*The declaration must conform to the standardized wording provided for in Section 212; see Notes to Boxes Nos. VIII, VIII (i) to (v) (in general) and the specific Notes to Box No. VIII (ii). If this Box is not used, this sheet should not be included in the request.*

Declaration as to the applicant's entitlement, as at the international filing date, to apply for and be granted a patent (Rules 4.17(ii) and 51bis.1(a)(ii)), in a case where the declaration under Rule 4.17(iv) is not appropriate:

in relation to this international application,

Institute of Materials Research and Engineering and National University of Singapore are entitled to apply for and be granted a patent by virtue of the following:

Institute of Materials Research and Engineering and National University of Singapore are entitled as employer of the inventors, TENG Jing Hua, CHUA Soo Jin and DONG Jian Rong.

This declaration is made for the purposes of all designations, except the designation of the United States of America.

on is continued on the following sheet, "Continuation of Box No. VIII (ii)".